



MAGNESIUM Pluoride Sputtering Target

Magnesium fluoride sputtering target is an inorganic compound with the formula MgF2. The main application of magnesium fluoride is in optics, due to its distinctive transparency over a wide range of wavelengths. It is evaporated under vacuum to form anti-reflective layers.

Quick Facts

Product Magnesium Fluoride Sputtering Target

NS6130-10-1294 Stock No

CAS 7783-40-6

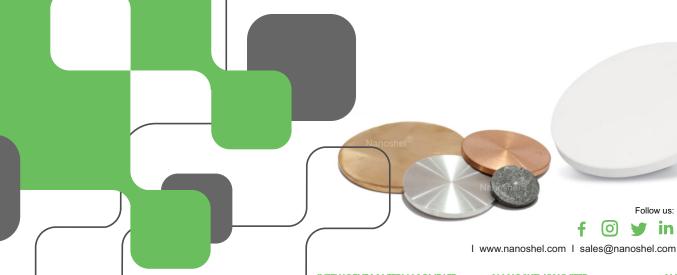
Backing Plate (As per Customer requirement)

Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1294	99.99%	50.8 mm ± 1mm	3 mm ± 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Melting Point
MgF ₂	62.301g/mol	1263°C







ISO 9001:2015 CERTIFIED COMPANY INTELLIGENT MATERIALS PVT LTD

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